

5.1 The concentration of donor impurity atoms in silicon is $N_d = 10^{15} \text{ cm}^{-3}$. Assume an electron mobility of $\mu_n = 1300 \text{ cm}^2/\text{V-s}$ and a hole mobility of $\mu_p = 450 \text{ cm}^2/\text{V-s}$.

(a) Calculate the resistivity of the material. (b) What is the conductivity of the material?

a) Per (5.20),
$$\rho = \frac{1}{\sigma} = \frac{1}{e(\mu_n n + \mu_p p)}$$
.

Assume $N_a = 0$. Table B.4 gives an intrinsic charge concentration $n_i = 1.5 \times 10^{10} \text{ #/cm}^3$ at 300 K for silicon. This is negligible compared to N_d . So, $n \approx N_d$. This also implies that p is negligible compared to n . For these approximations, this gives a resistivity of

$$\rho \approx \frac{1}{e \mu_n N_d} = \frac{1}{1.602176634 \times 10^{-19} (1300) 10^{15}} \Rightarrow \underline{\underline{\rho = 4.80116 \text{ } \Omega\text{-cm} = 0.048012 \text{ } \Omega\text{-m.}}}$$

b) Since $\sigma = 1 / \rho = 1 / 0.048012 \Rightarrow \underline{\underline{\sigma = 20.828 \text{ S/m} = 0.20828 \text{ S/cm.}}}$